



CARBON COATING OF THE SPS DIPOLES

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Introduction

Coating techniques

Results

Conclusions

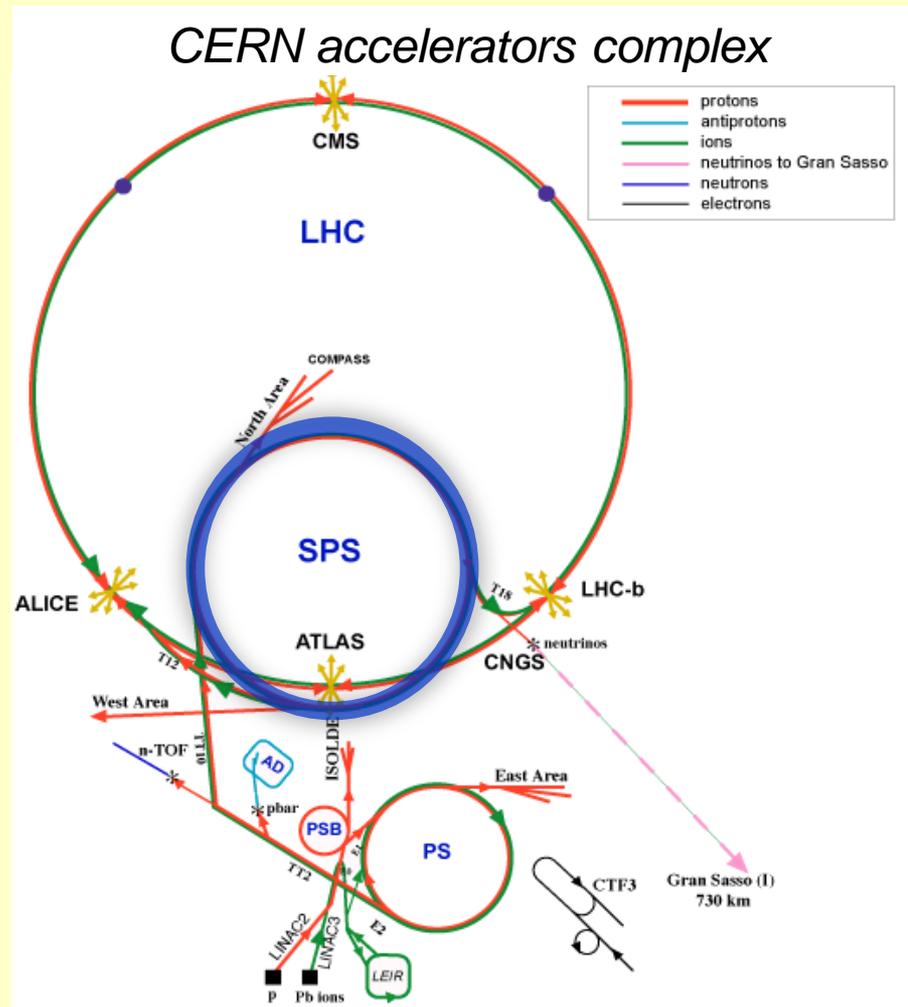


For the Large Hadron Collider to work at his design luminosity, the Super Proton Synchrotron (SPS) must be able to feed him with proton beams 25 ns spaced bunches accelerated at 450 GeV.

With the actual configuration of the machine, this beam induces Electron Multipacting (EM), causing emittance blow up and beam losses.

One way to mitigate EM is to coat the internal walls of the beampipes with a material having a maximal Secondary Electron Yield (SEY), below 1.3. ($\delta_{max} < 1.3$)

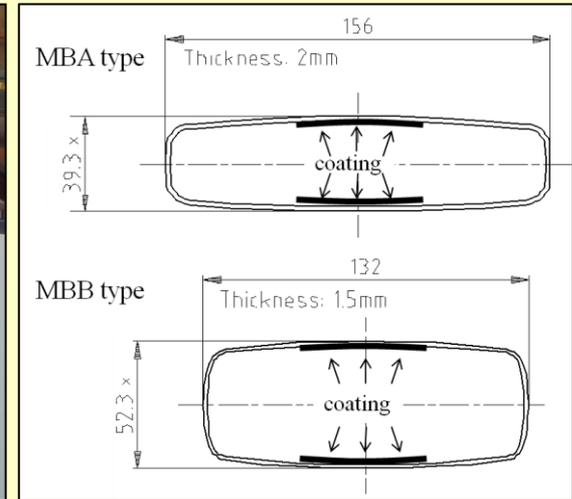
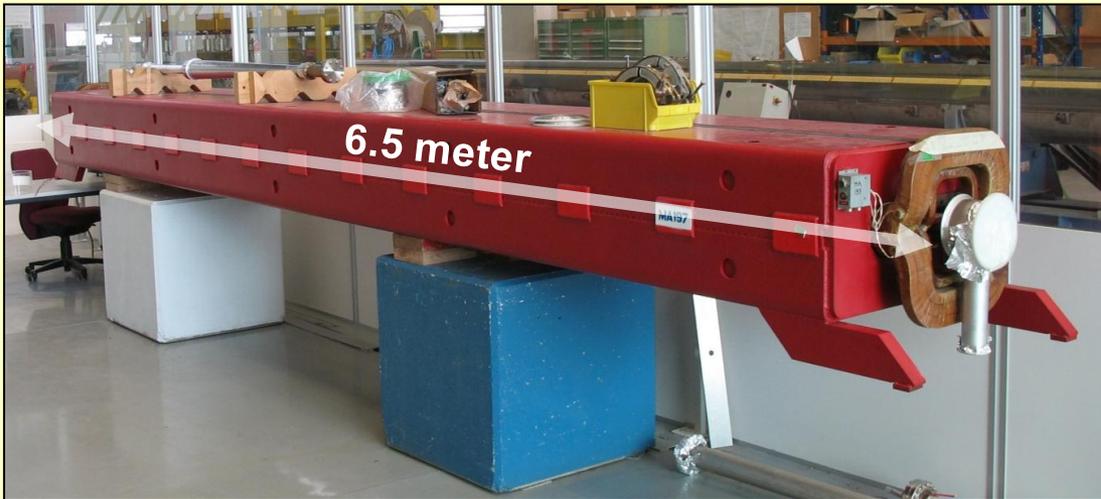
Carbon was chosen because of low SEY of graphite (~1.0) and low chemical reactivity





Almost 5 km of the SPS are filled with MBB and MBA type dipoles (>700).

The length of each dipole is 6.5 m and weights ~18 tons.



The beampipes are embedded in the yoke.



coat new beampipes, open the dipole,
insert beampipe, close the dipole.

coat the actual beampipes directly in
the dipole.

Easy to coat

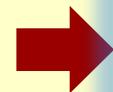
Too expensive (open/close dipole)

Easy to coat

cheaper



coat new beampipes, open the dipole, insert beampipe, close the dipole.



DC Cylindrical Magnetron Sputtering (DCCMS)

coat the actual beampipes directly in the dipole.



DC Planar Magnetron Sputtering (DCPMS) using the dipoles field

DC Planar Magnetron Sputtering (DCPMS) using Permanent Magnets

Plasma Enhanced Chemical Vapor Deposition (PECVD) from C_2H_2

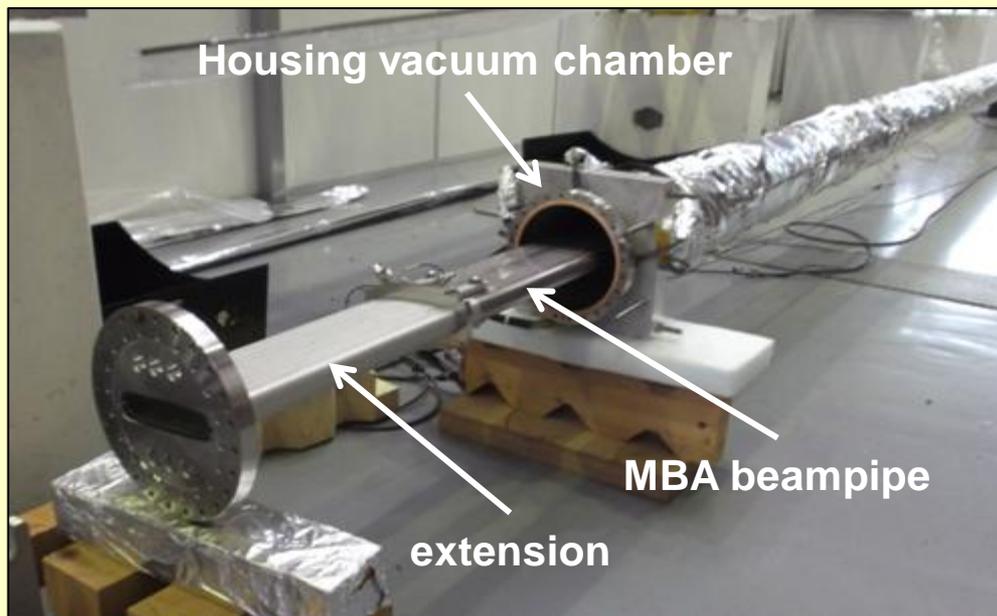
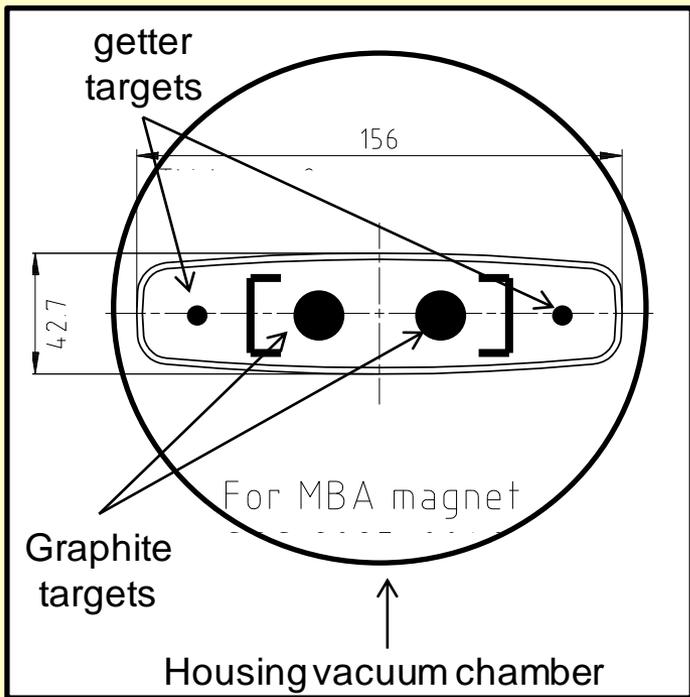
DC Hollow Cathode Sputtering (DCHCS)

The sputtering techniques all give carbon coatings with $\delta_{max} \sim 1$.

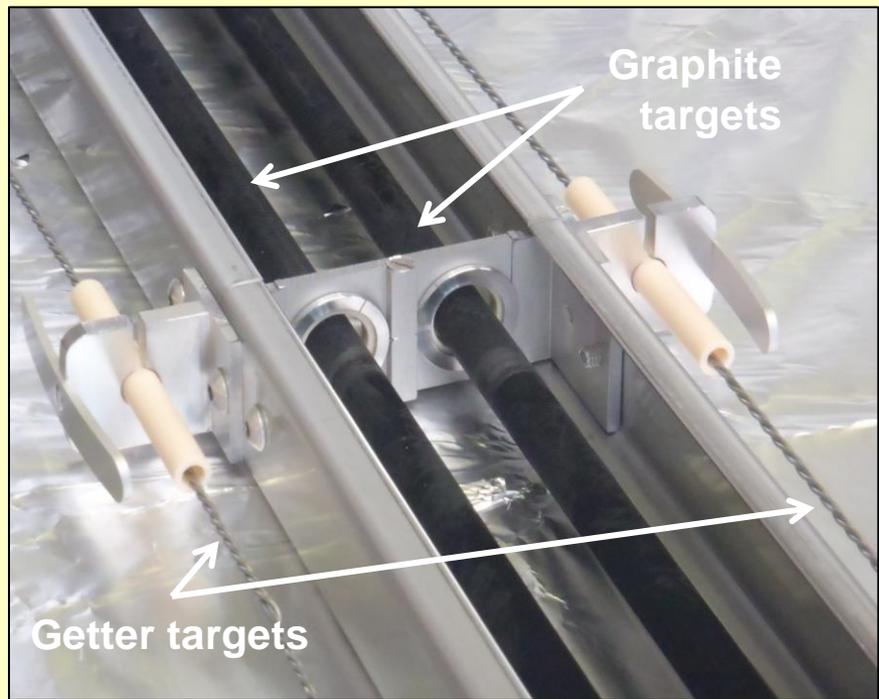
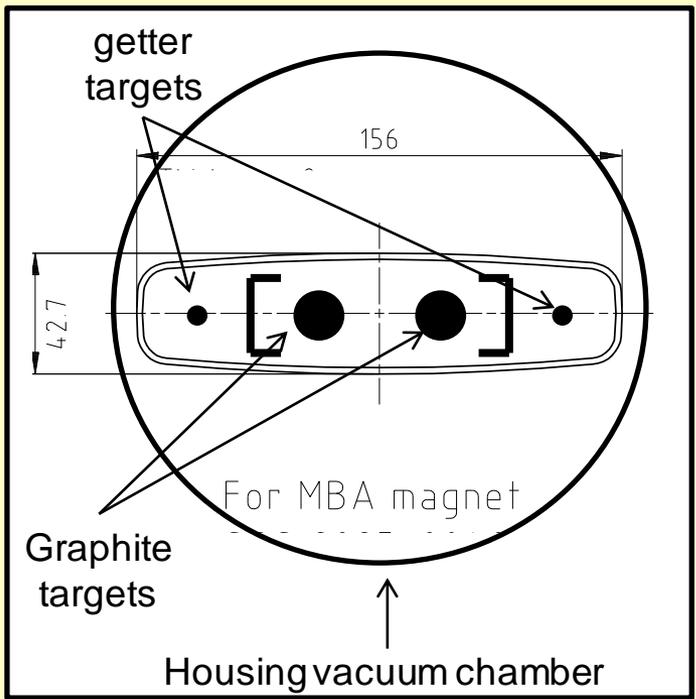
PECVD give carbon coatings with $\delta_{max} \sim 1.5$.



Coat new beampipes by DC Cylindrical Magnetron Sputtering (DCCMS)

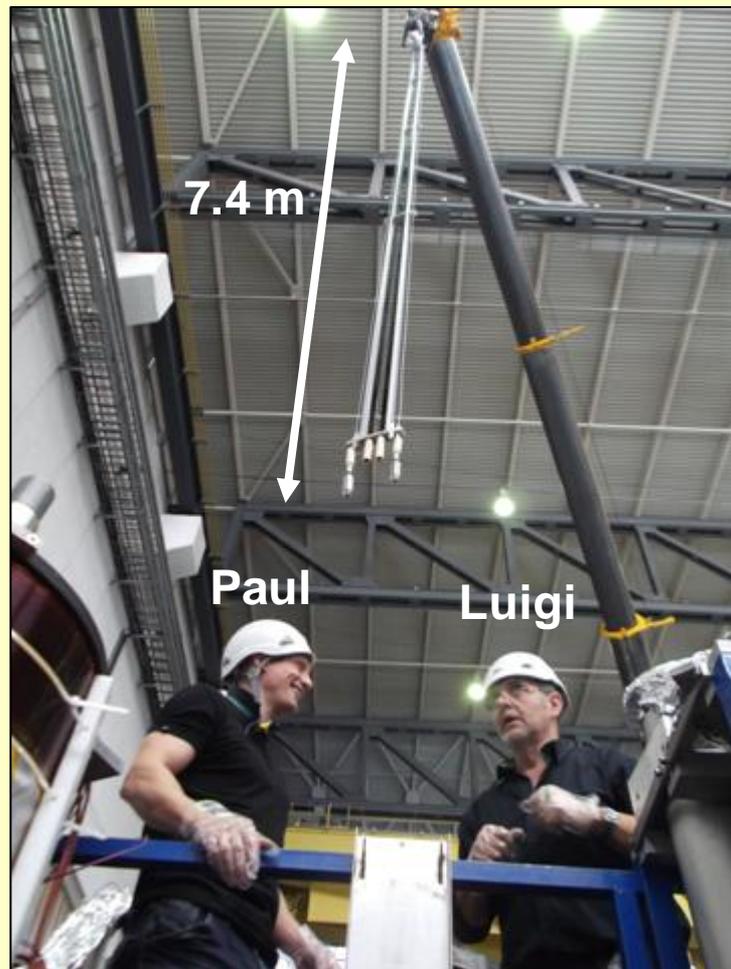
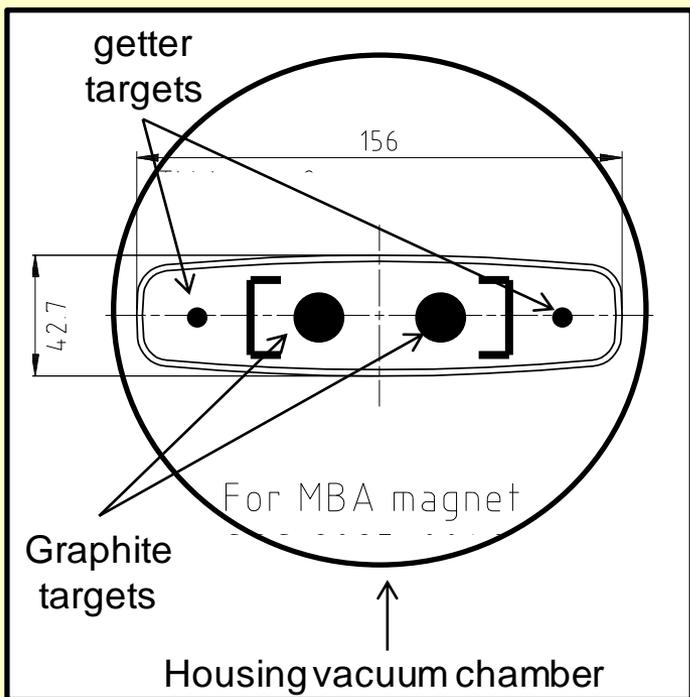


Coat new beampipes by DC Cylindrical Magnetron Sputtering (DCCMS)



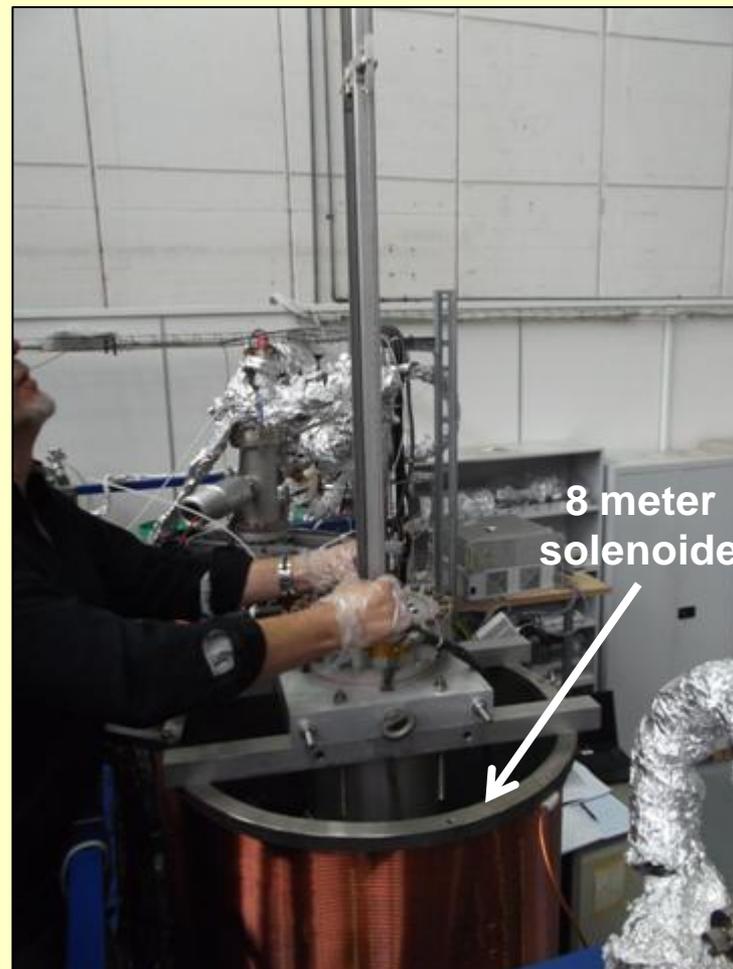
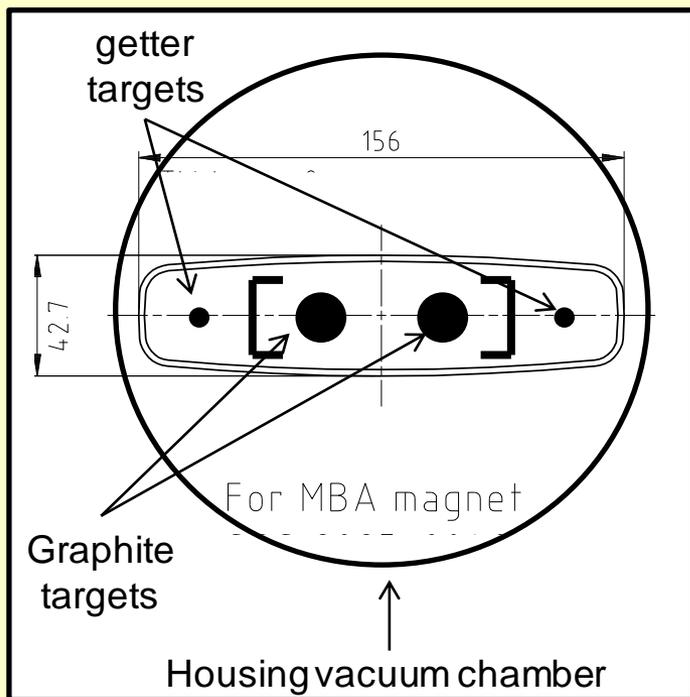


Coat new beampipes by DC Cylindrical Magnetron Sputtering (DCCMS)



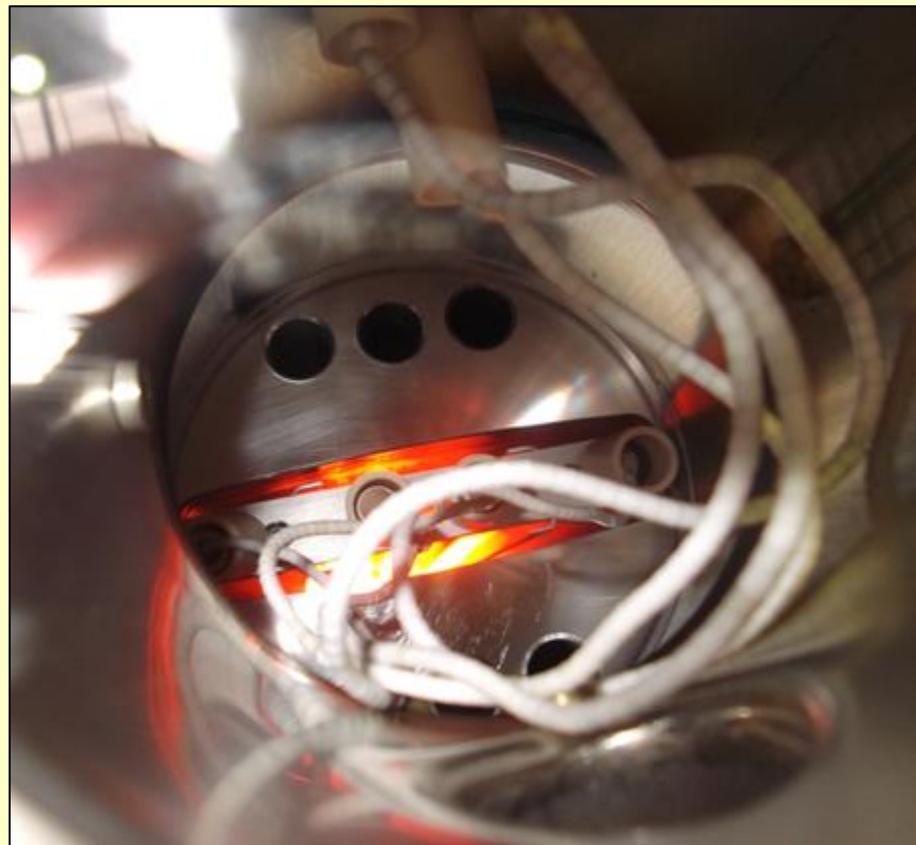
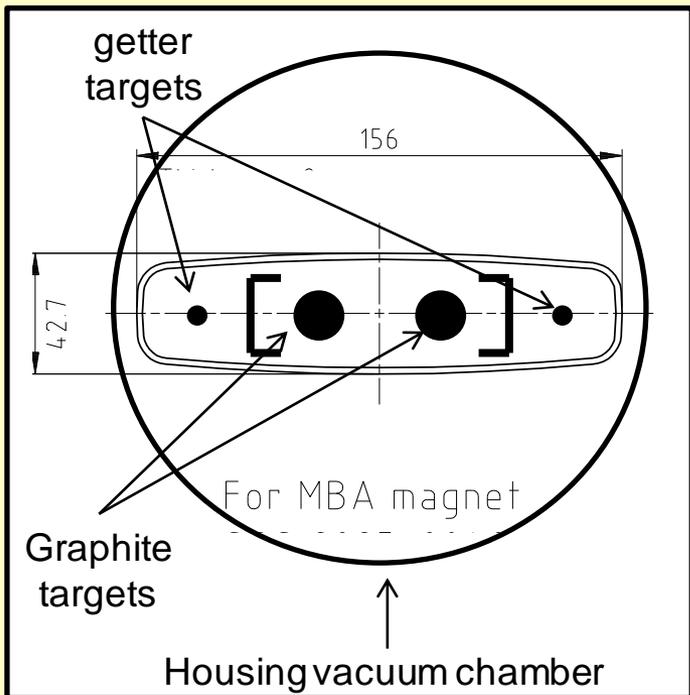


Coat new beampipes by DC Cylindrical Magnetron Sputtering (DCCMS)





Coat new beampipes by DC Cylindrical Magnetron Sputtering (DCCMS)



Pressure: 1.2×10^{-1} mbar (Ne)

Power: 1.8 kW (3A @ 600 V)

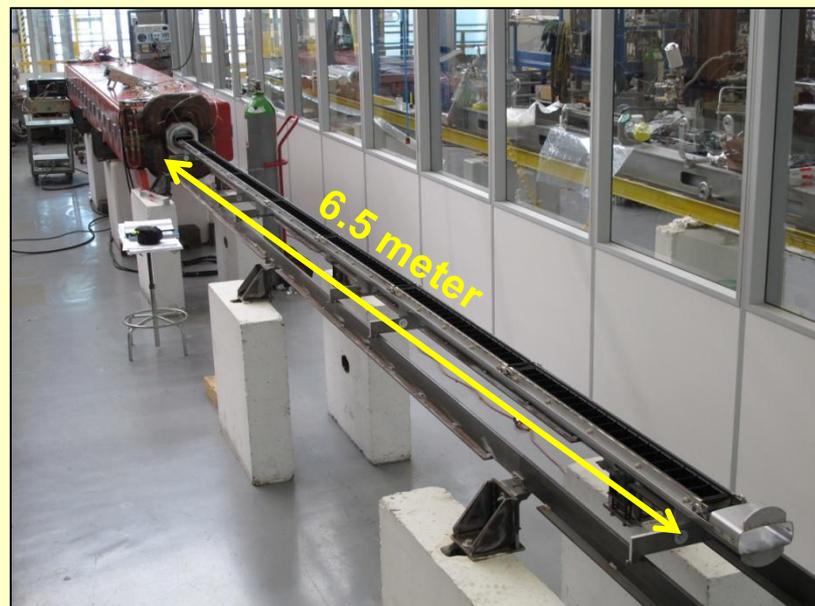
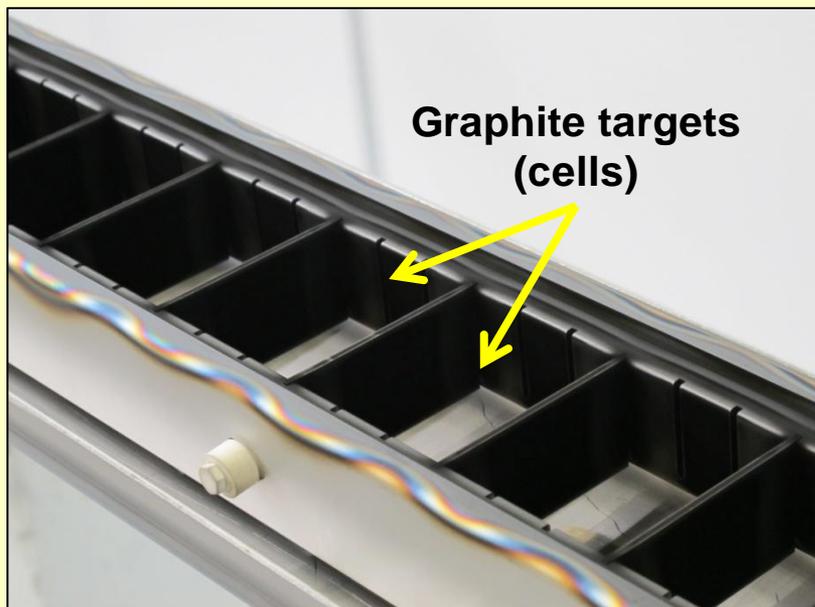
B: 180 Gauss



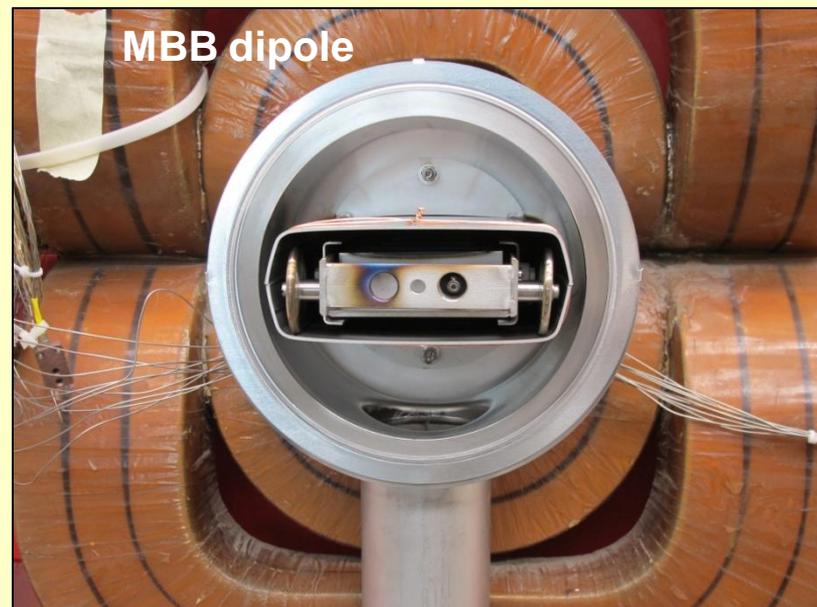
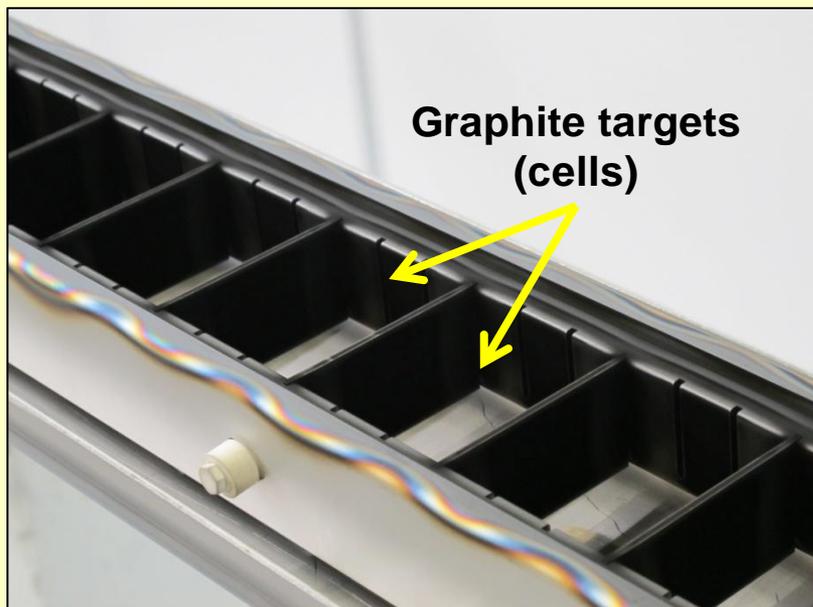
0.5 μ m in 8 hours

THE TECHNIQUE IS MATURE FOR LARGE SCALE PRODUCTION

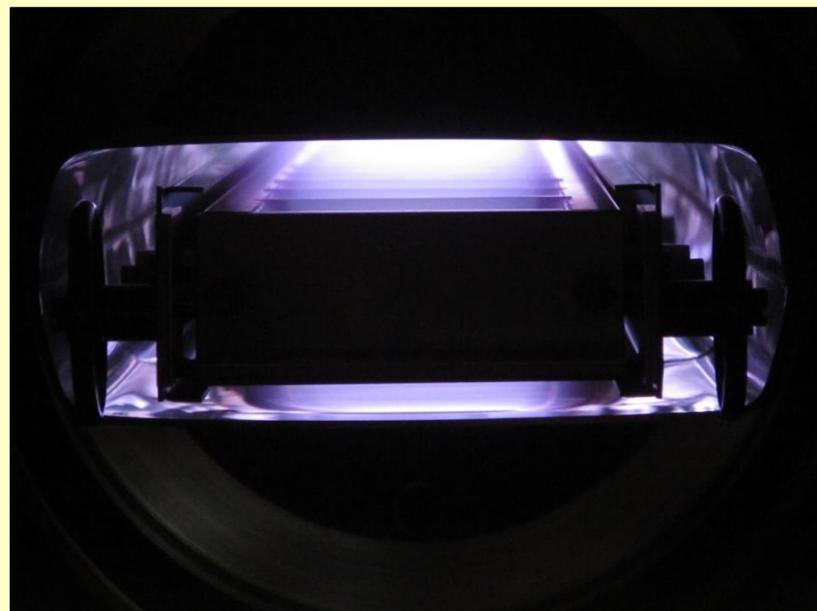
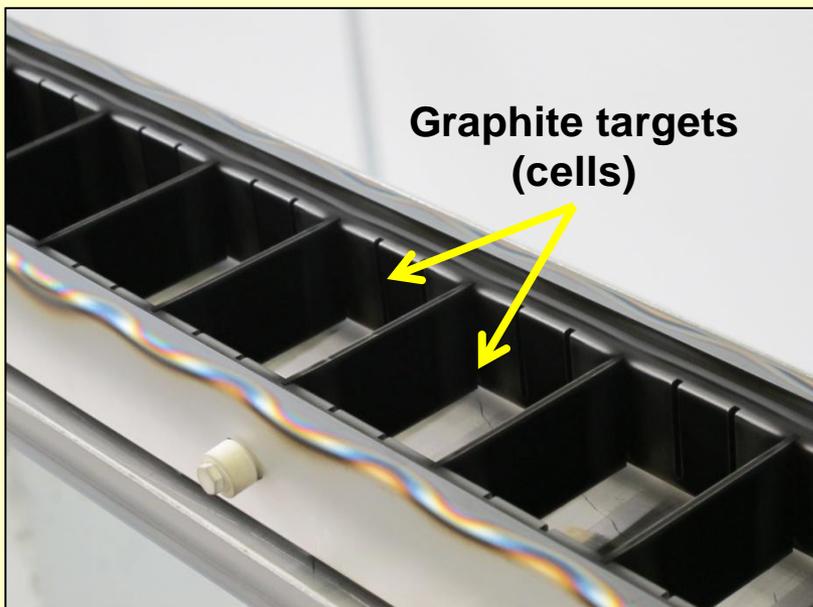
Coat actual beampipes by DC Hollow Cathode Sputtering (DCHCS)



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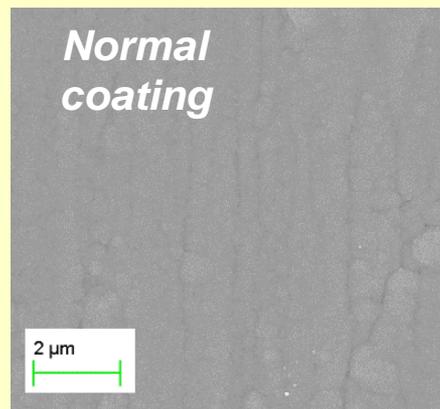
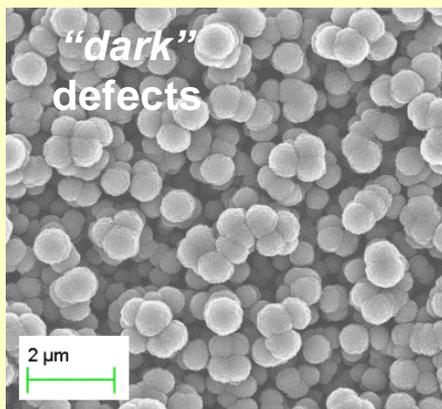
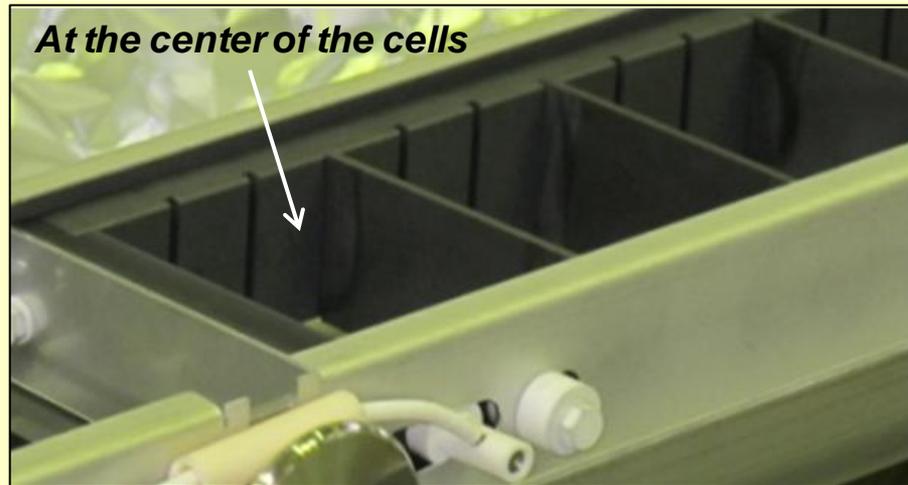
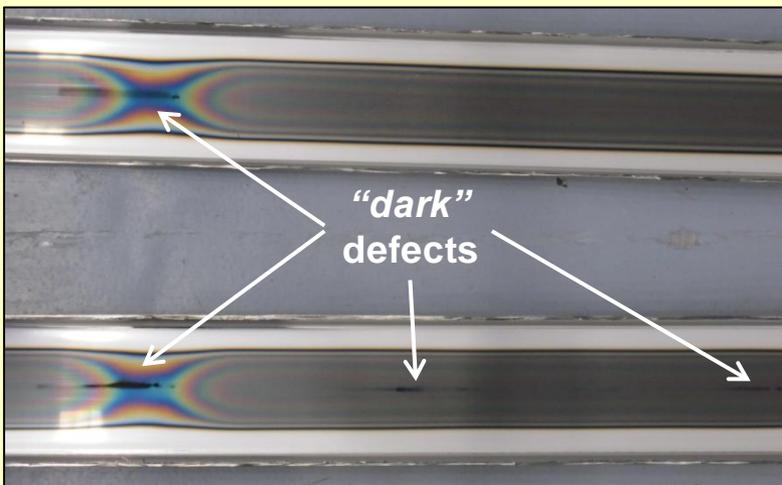


Pressure: 2.4×10^{-1} mbar (Ar)
Power: 1.8 kW (3A @ 600 V)
0.5 μ m in 20 hours

THE TECHNIQUE IS ALMOST MATURE FOR LARGE SCALE PRODUCTION

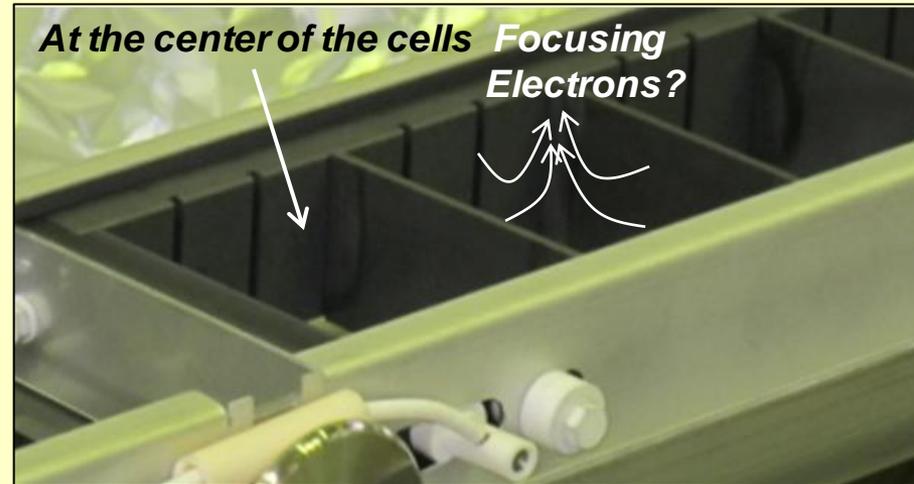
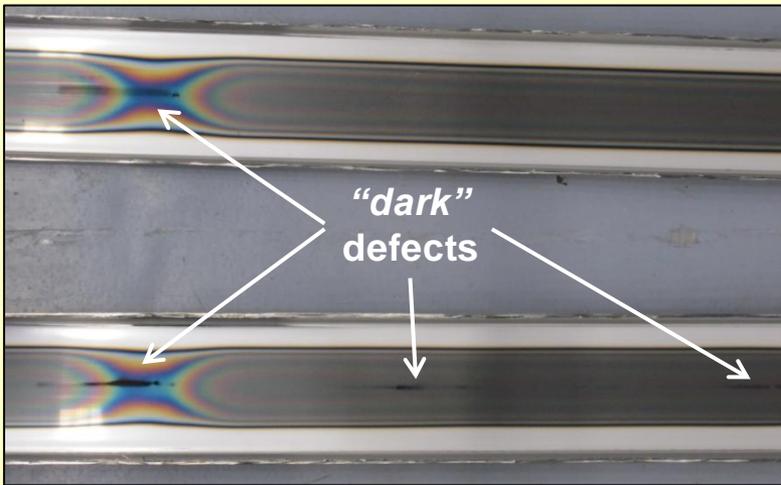
Why almost?

Some “dark” defects appear along the central line of the chamber



Why almost?

Some “dark” defects appear along the central line of the chamber



Electrons
focused into
the center of
the cells



Increase ion
density near
the substrate



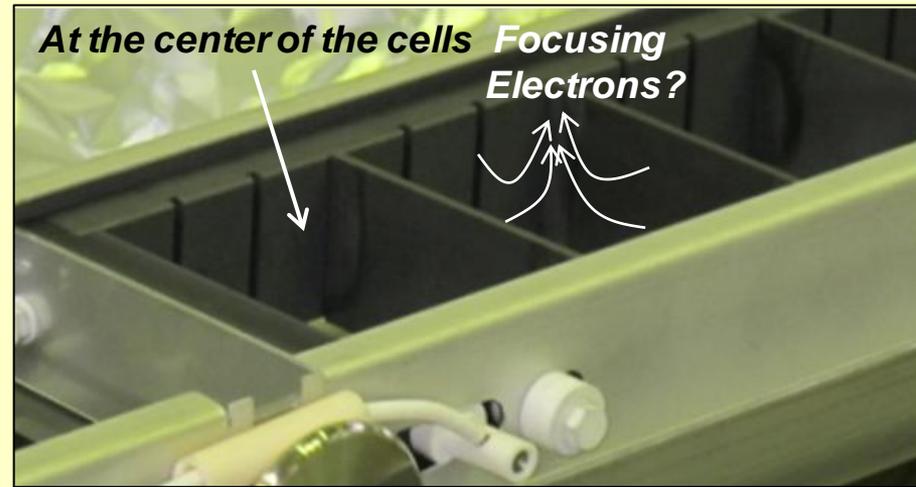
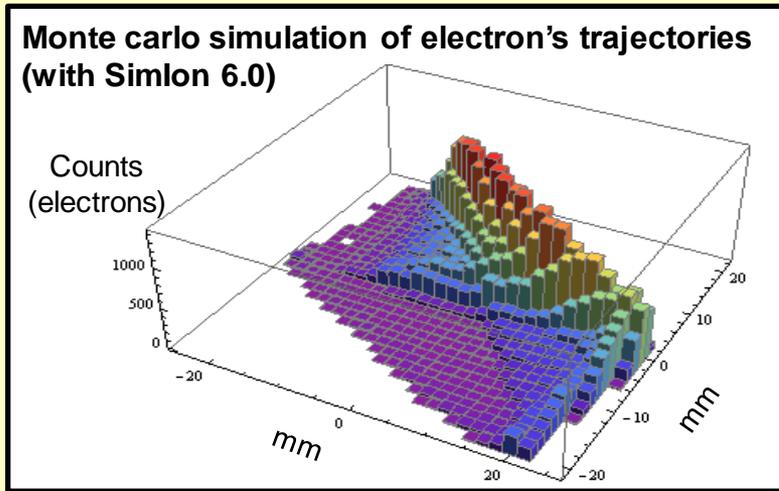
Low energy ion
bombardment



Structure modification
(equivalent to temperature)

Why almost?

Some “dark” defects appear along the central line of the chamber



Electrons focused into the center of the cells



Increase ion density near the substrate



Low energy ion bombardment

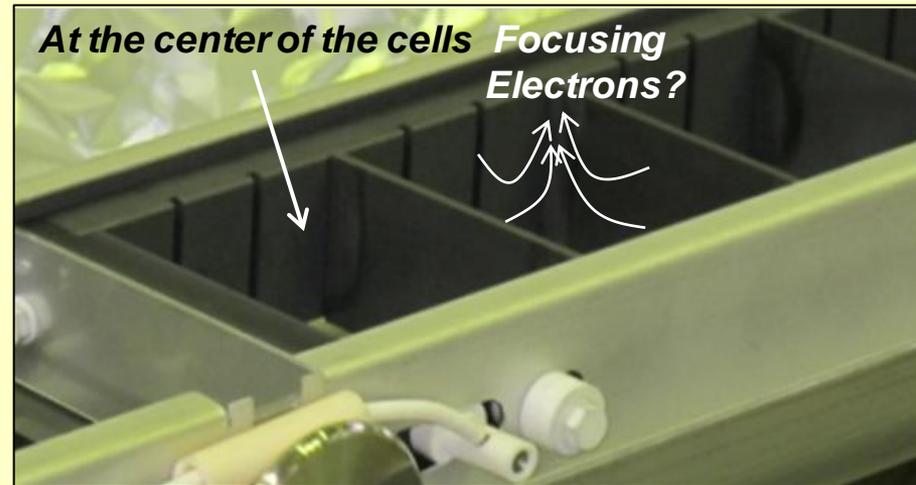
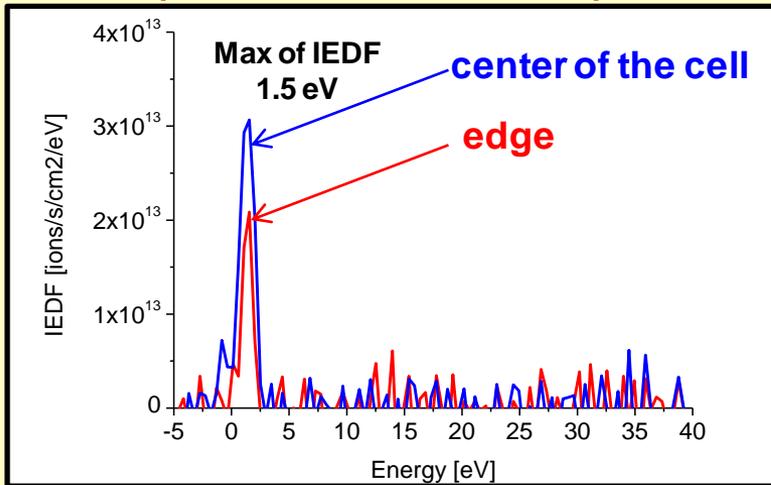


Structure modification (equivalent to temperature)

Why almost?

Some “dark” defects appear along the central line of the chamber

Ions Energy Distribution Function (measured with RFEA)



Electrons focused into the center of the cells



Increase ion density near the substrate



Low energy ion bombardment

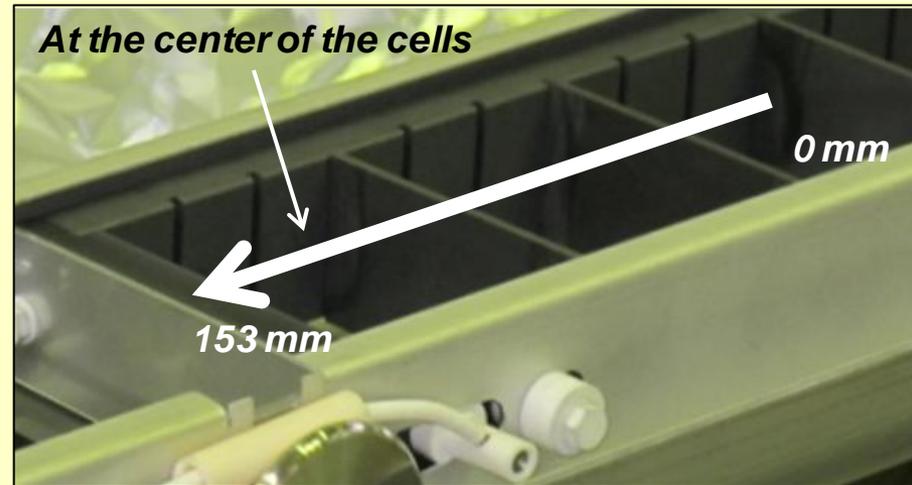
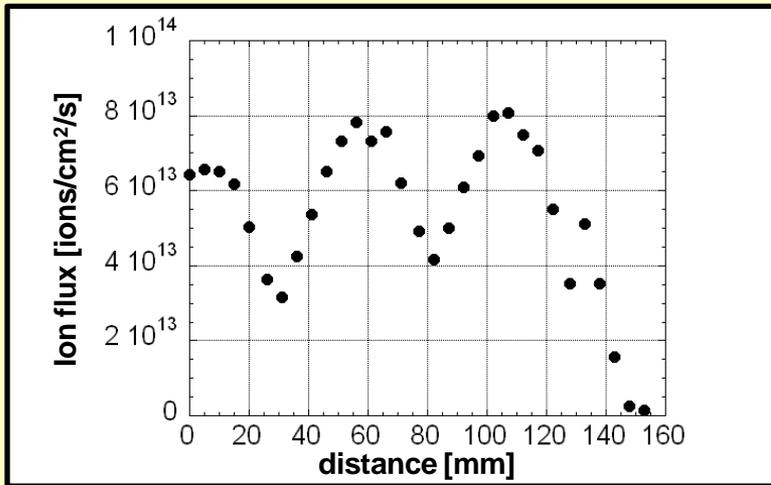


Structure modification (equivalent to temperature)

Why almost?

Some “dark” defects appear along the central line of the chamber

Ion flux along the cells



Electrons focused into the center of the cells



Increase ion density near the substrate



Low energy ion bombardment

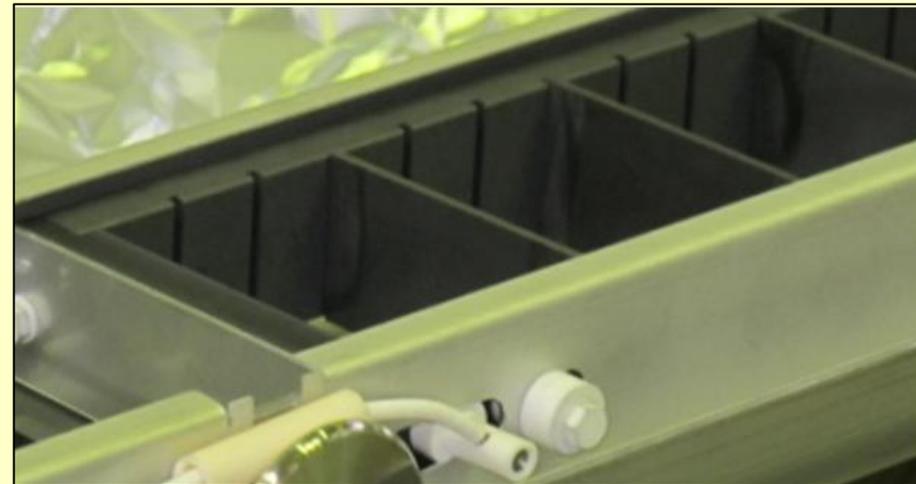
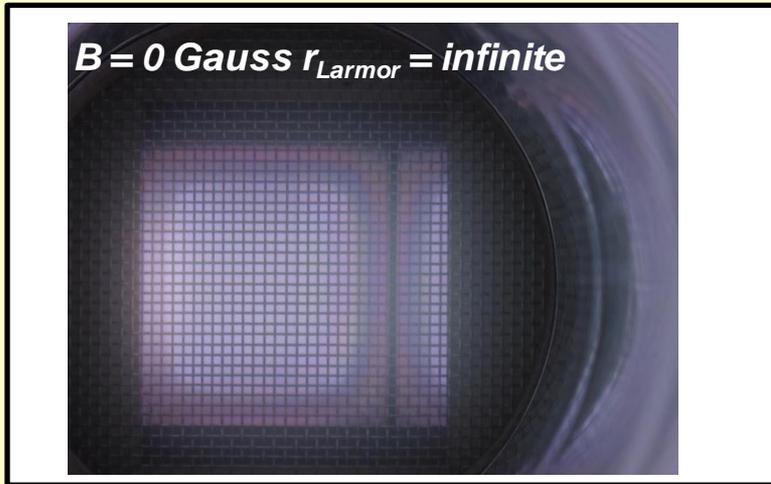


Structure modification (equivalent to temperature)

How to solve the problem?

Use the dipole's magnetic field to avoid the electrons to reach the center of the cell: Larmor radius $\ll 25$ mm (half cell)

Tests in 25cm prototype



Electrons focused into the center of the cells



Increase ion density near the substrate



Low energy ion bombardment

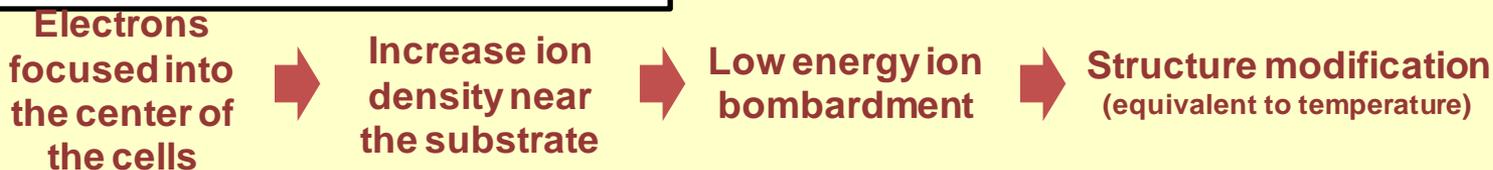
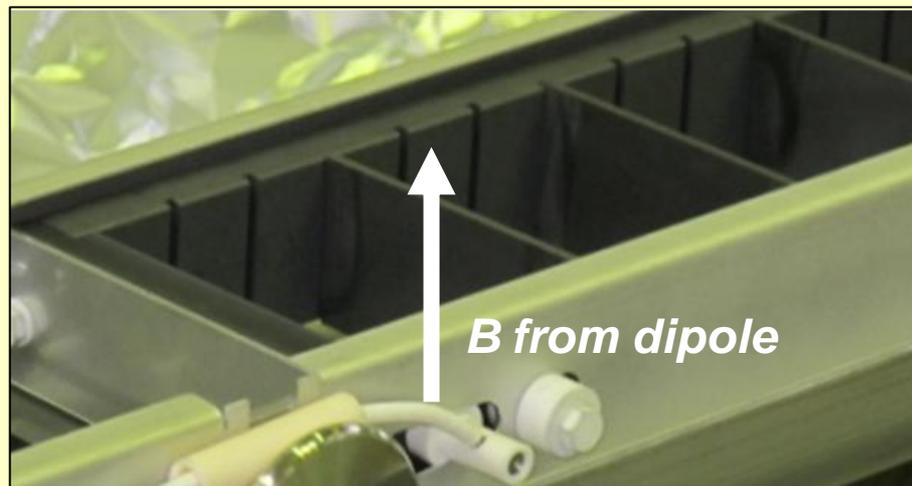
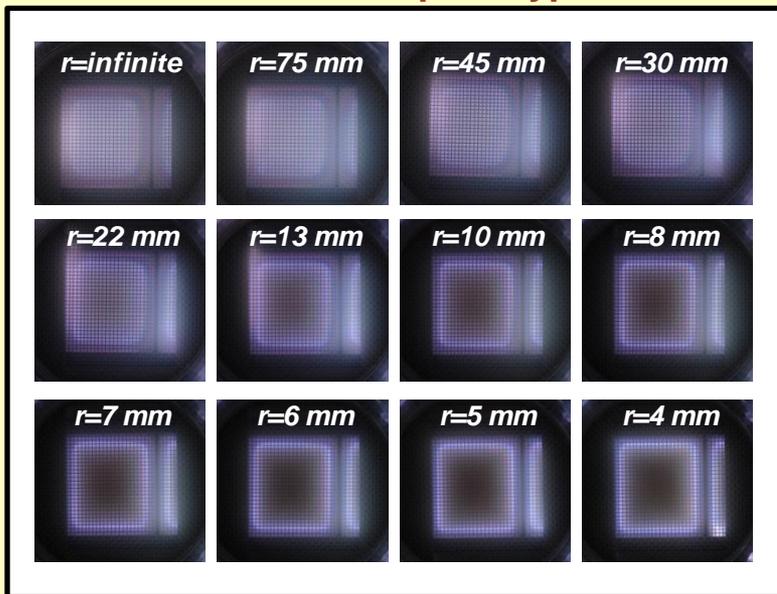


Structure modification (equivalent to temperature)

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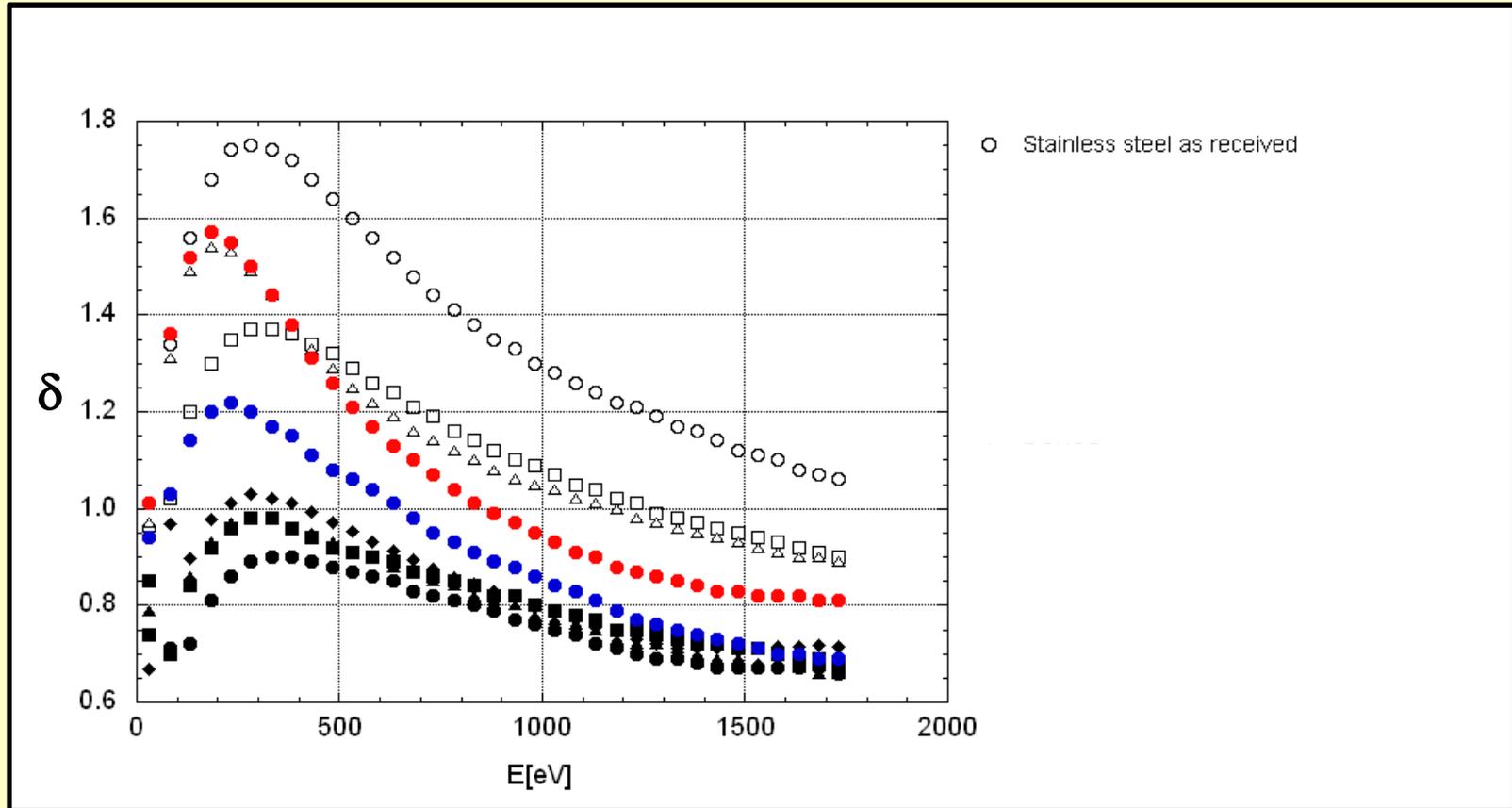
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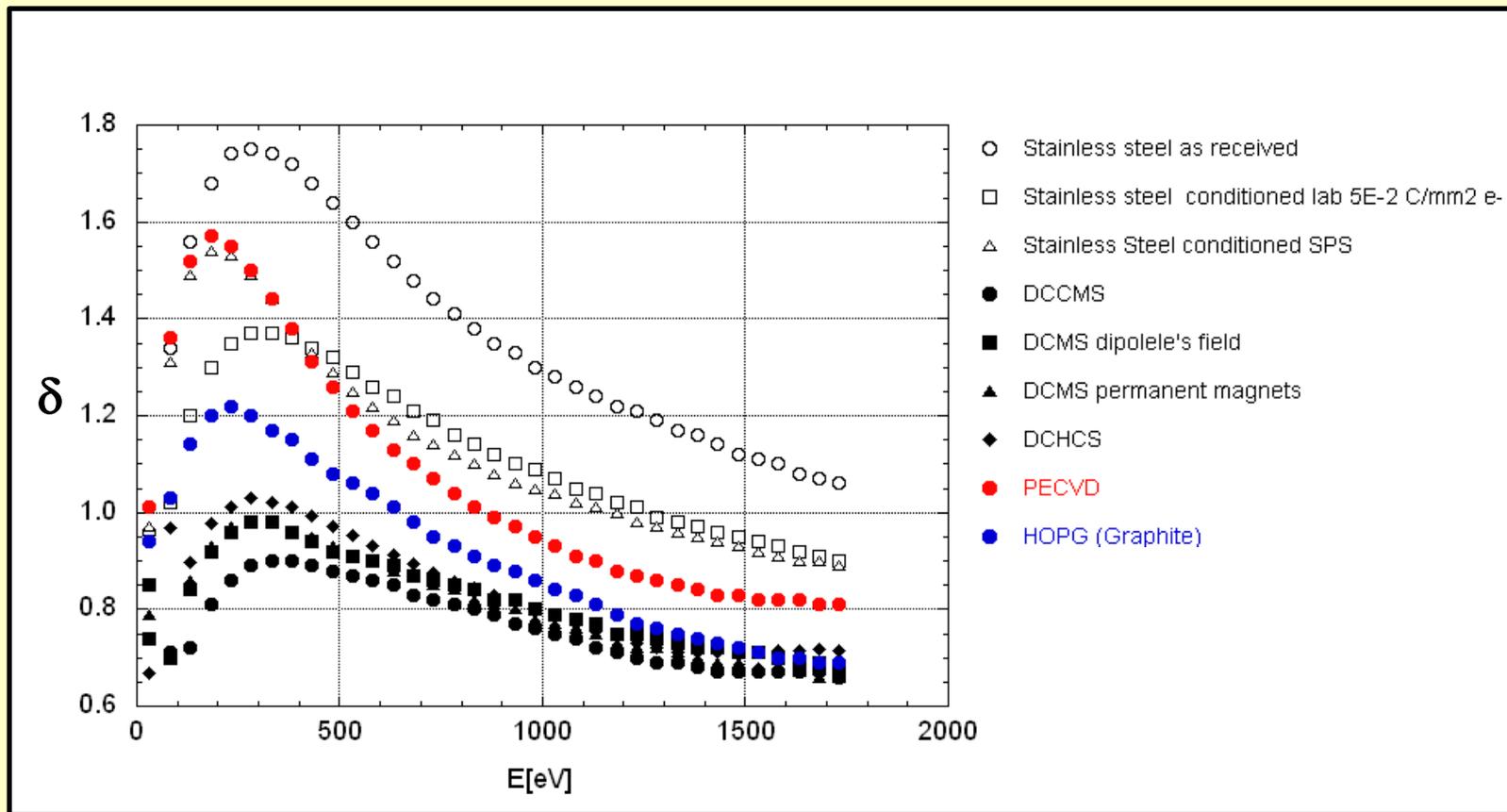


Next steps: check if ion flux distribution follows; apply this to coat a real dipole

SEY versus the energy of primary electrons

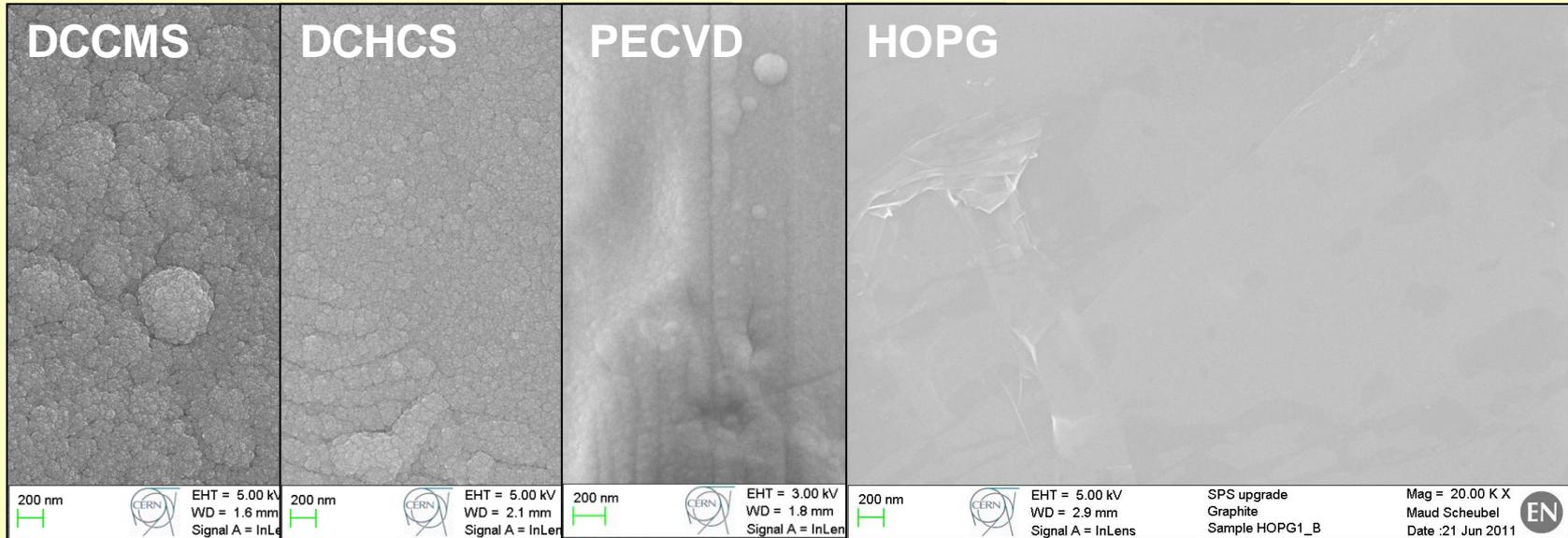


SEY versus the energy of primary electrons



*Coatings obtained by sputtering are similar
PECVD coatings have high SEY*

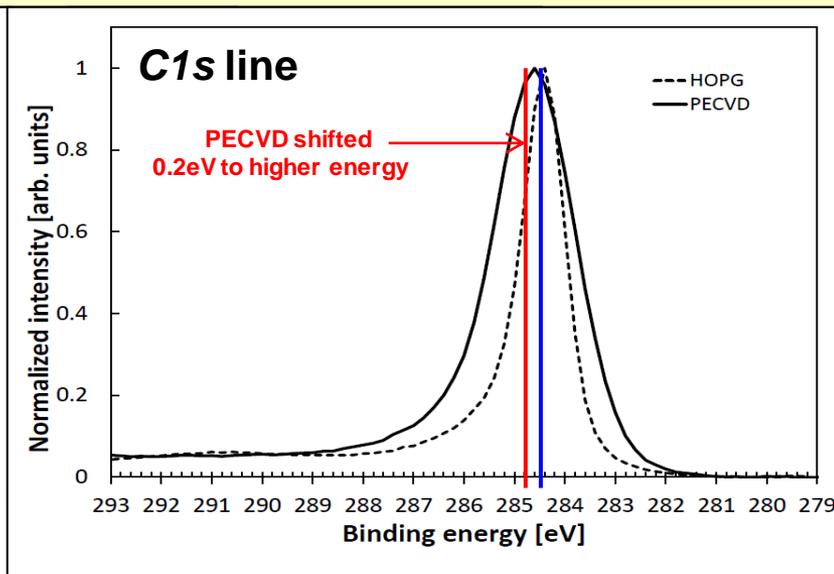
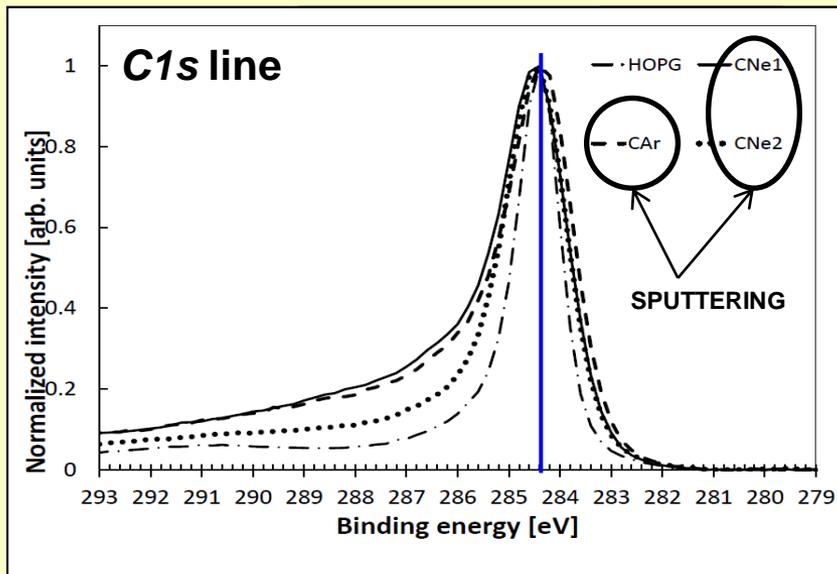
Coatings morphology



Roughness could explain the lower δ_{\max} of sputtered coatings relative to HOPG

But not the high δ_{\max} of PECVD coatings

XPS analysis



Sputtered coatings and HOPG have the maxima at 284.4 eV => typical of graphite, sp^2 bonds

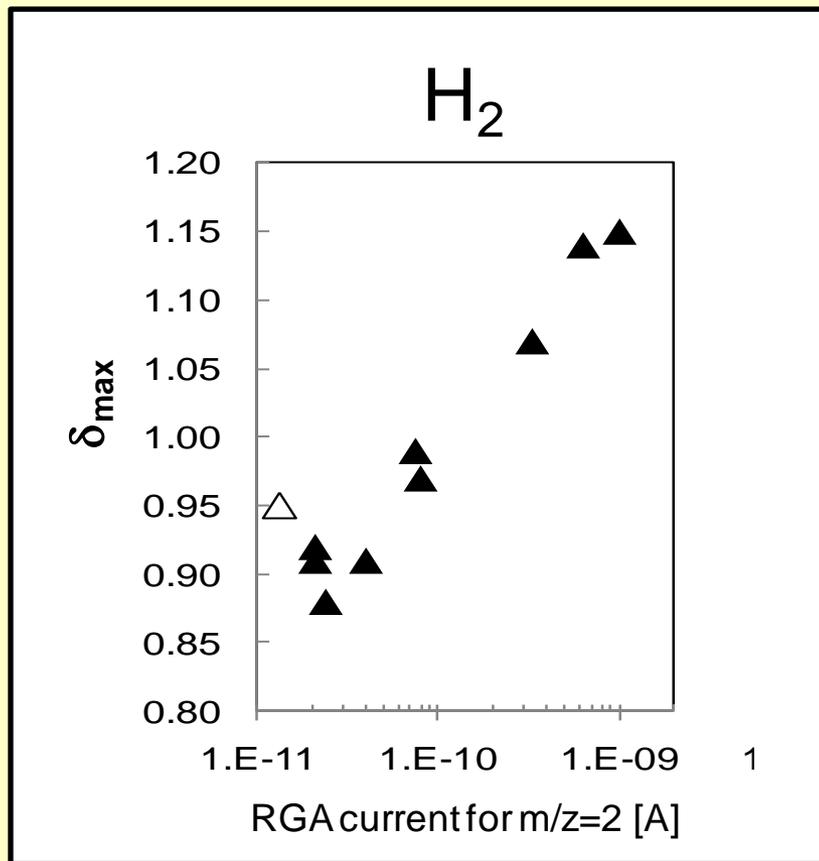
PECVD coatings have the maxima shifted by 0.2eV to high binding energies => the fraction of sp^3 bonds start to be important => more “diamond like”

Hydrogen in carbon coatings favors sp^3 bonds [28] J. Robertson, *Material Science and Engineering R37 (2002) 129-281.*

As hydrogen is inherent to the PECVD process (precursor is C_2H_2), this technique was discarded for low SEY coatings.

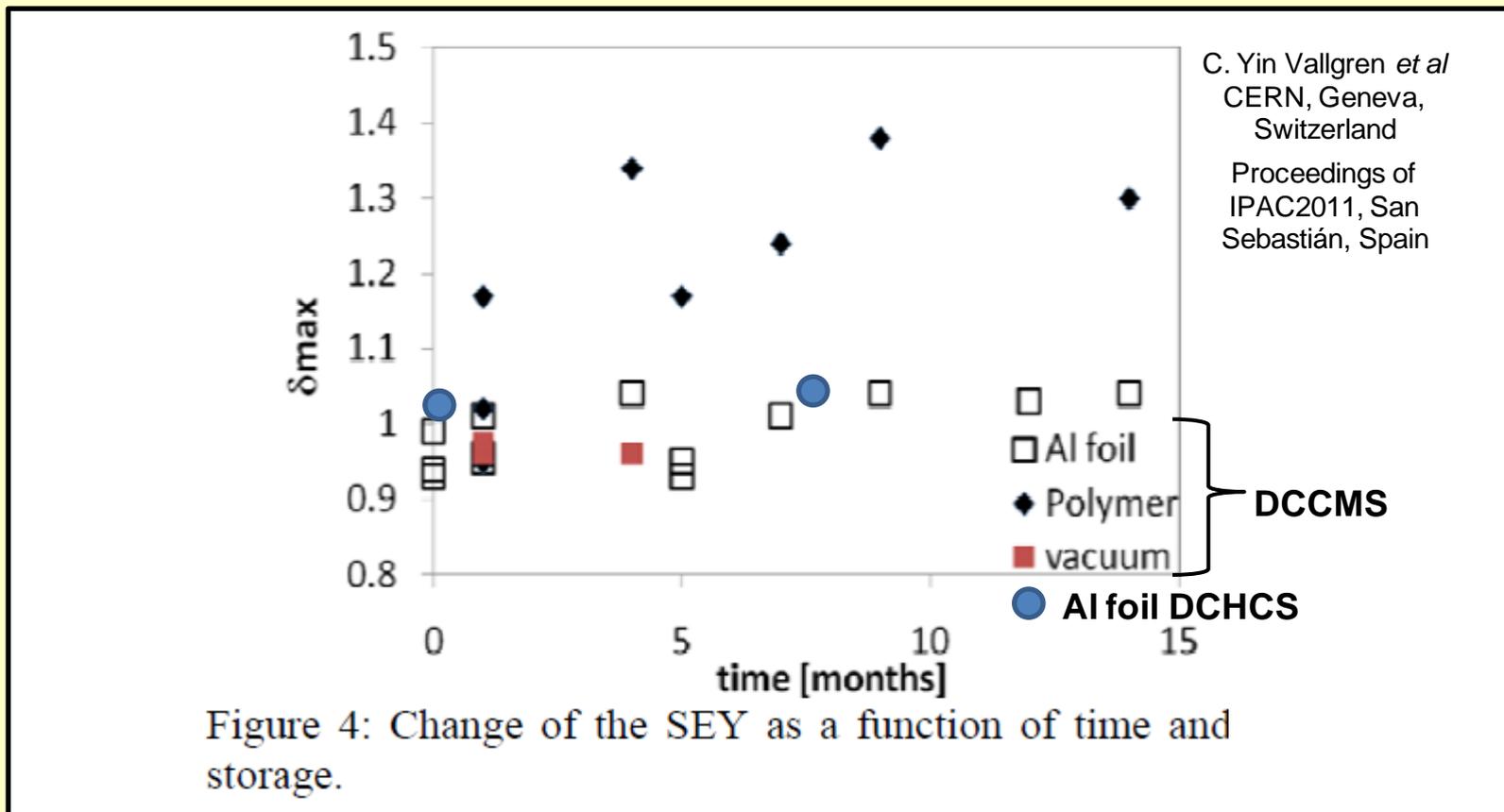


Max SEY (δ_{max}) versus hydrogen in the plasma during the coating by sputtering



The influence of Hydrogen in sputtered coatings is confirmed by experiments where H_2 is deliberately injected during the coating process

Max SEY (δ_{max}) versus time and storage conditions

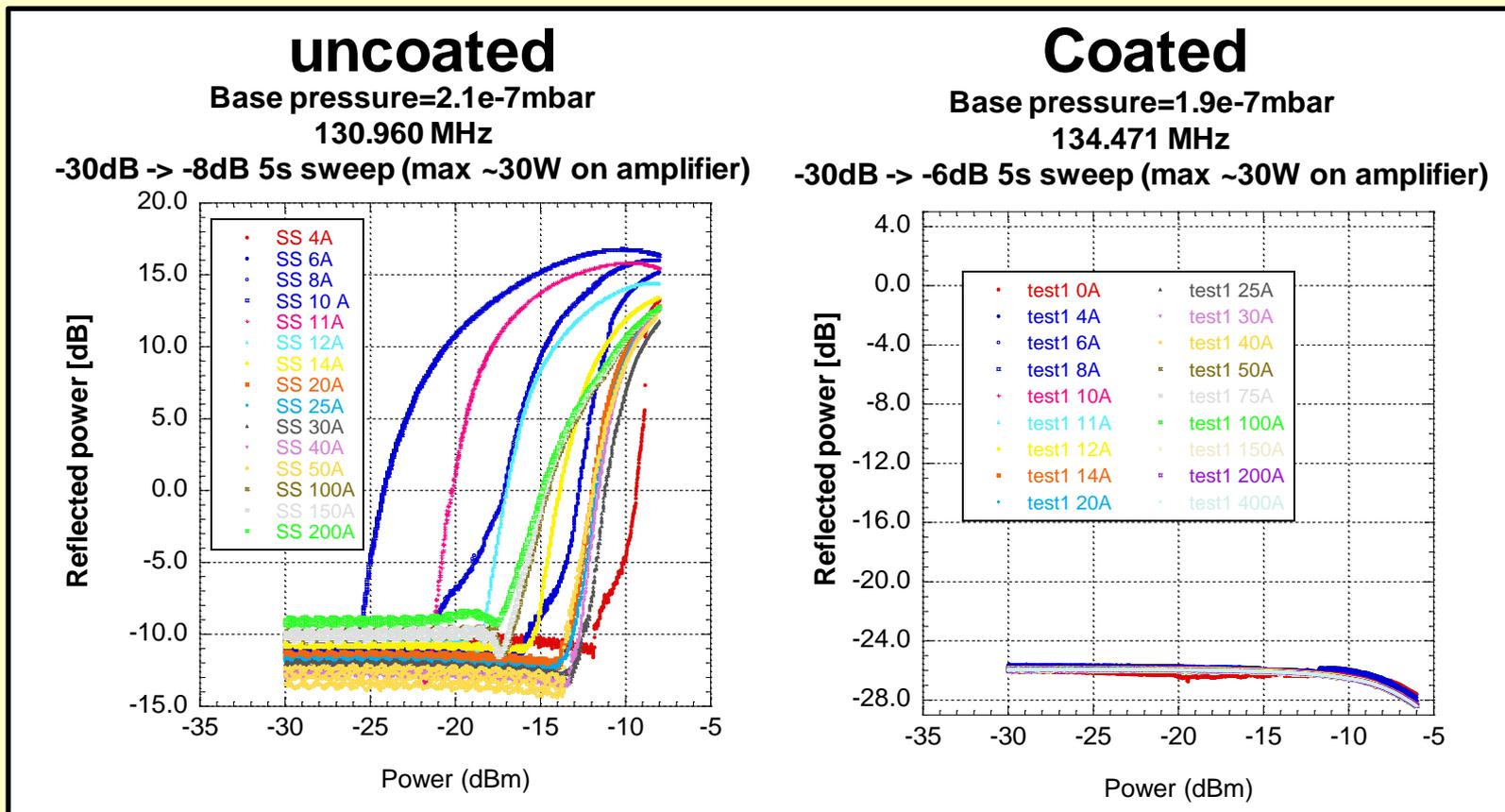


Simple storage, (Al foil, flanges, etc.), is enough to prevent ageing in air.

Ageing not yet understood... but mastered!



Tests in the “Multipactor” system (see Fritz Caspers talk (79) this afternoon)

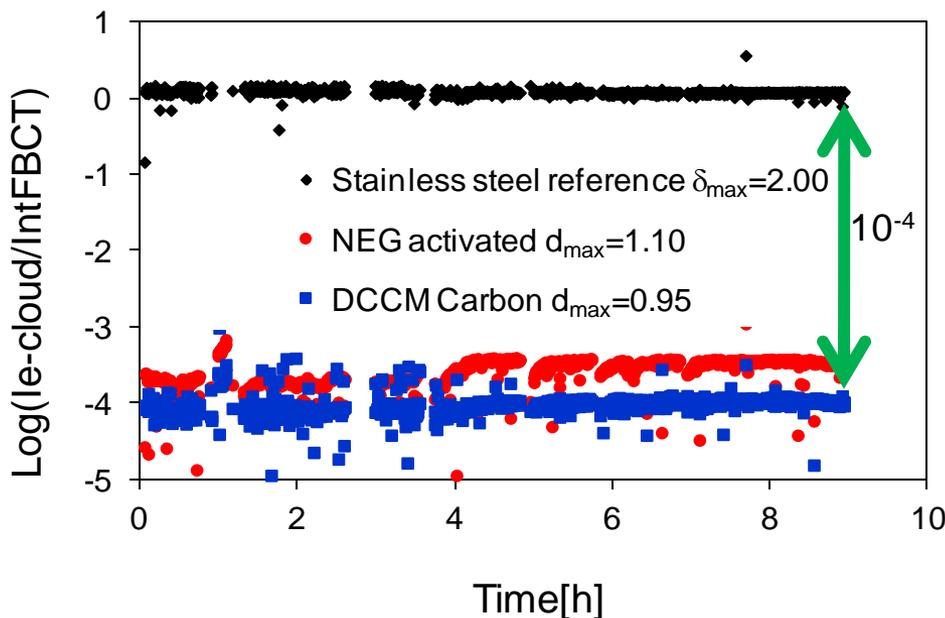


Uncoated dipoles present strong multipacting, dependent of the magnetic field (cyclotron resonance)

Coated dipoles shows no multipacting

Results from Electron Cloud Monitors in the SPS

Set-up: carbon coated liners with strip detector in 1.2K Gauss field
 Beam: 2-3 batches, 72 proton bunches, 25 ns spacing, 450 GeV



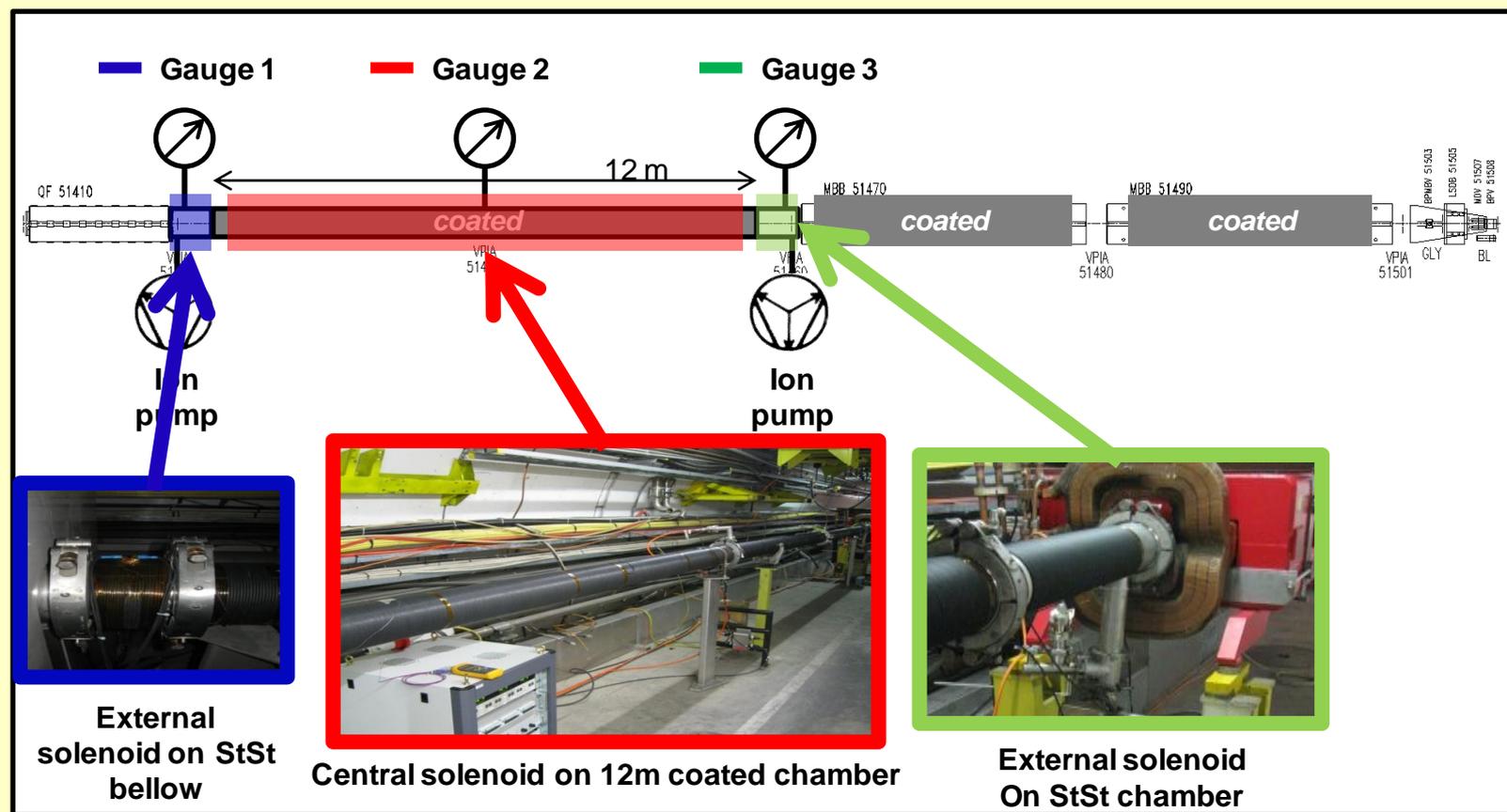
Ageing in the SPS

Liner	Time in SPS	δ_{max} initial	δ_{max} extracted
StSt (Ref)	1 year (5 MD runs)	2.25	1.72
C-strip (40mm)	1 year (5 MD runs)	0.92	0.97
C-Zr	1.5 years (9 MD runs)	0.95	0.99
CNe64	3 months (2 MD runs)	0.95	0.97
CNe65	3 months (2 MD runs)	0.95	0.97

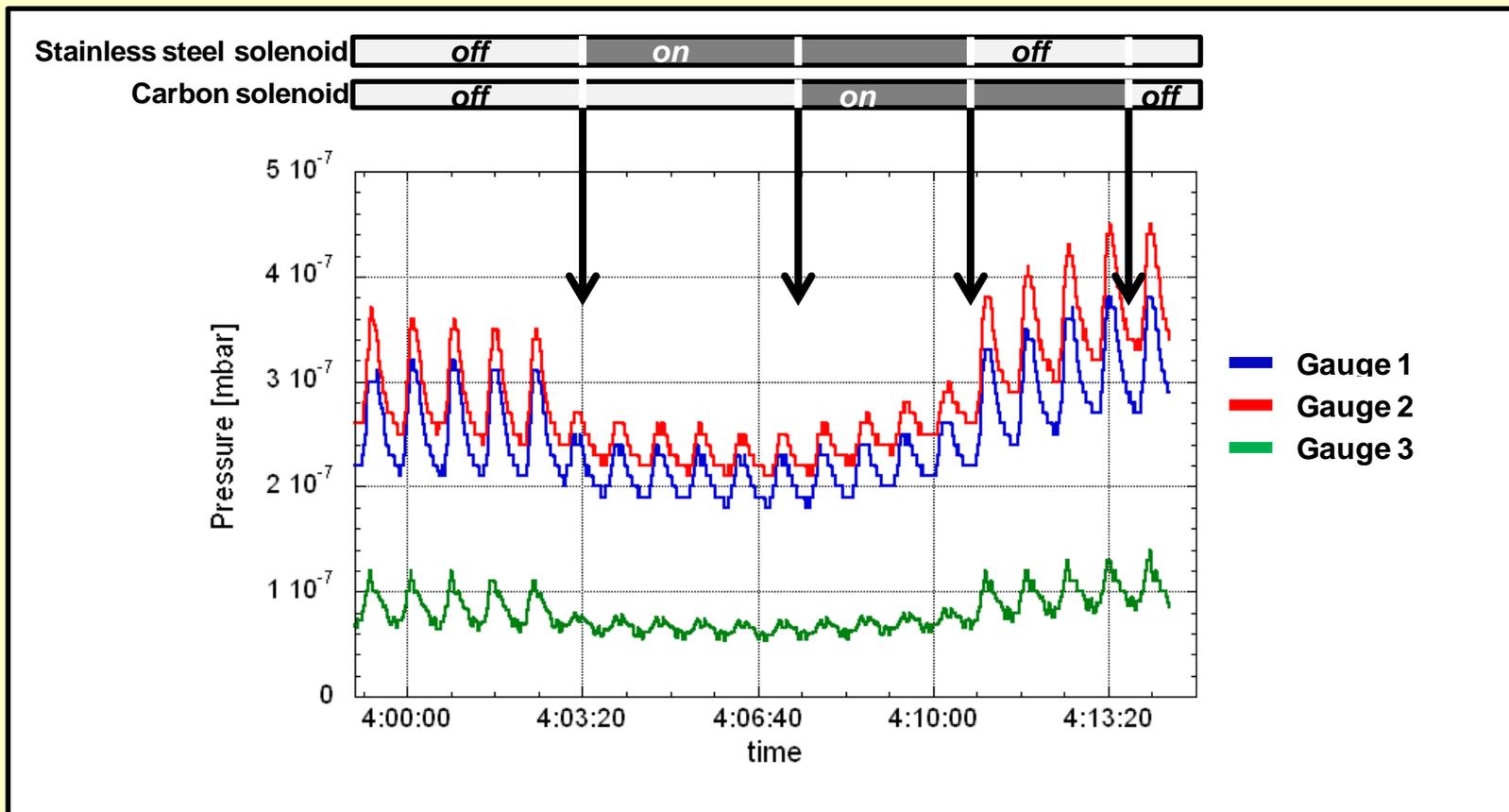
E-cloud signal for carbon is 4 orders of magnitude below that for stainless steel.

Negligible ageing
 (accuracy of SEY measurements +/- 0.03)

Dynamic pressure measurements in a drift zone of the SPS



Dynamic pressure measurements in a drift zone of the SPS



**Solenoid in carbon coated chamber has no effect in pressure
=> NO E-CLOUD**



- 1 – Sputtered films are better than PECVD. (very likely due to higher sp^2/sp^3 ratio)
- 2 – H_2 is the key parameter to keep $\delta_{max} \sim 1.0$ in sputtered films.
- 3 – ageing in air OK: negligible if sample protected(Al foil, flanges, etc.)
- 4 – ageing in the SPS OK: negligible (ECMs).
- 5 – ECM in SPS OK: coated liners have 10^4 less multipacting than stainless steel.
- 6 – Multipactor tests OK: multipacting before coating, no multipacting after coating.
- 7 – Dynamic pressure tests in SPS OK: effect of solenoid in stainless steel parts, no effect in coated parts.
- 8 – So far, the sputtered carbon coatings passed all the tests.
- 9 – DCCMS technique is “ready to go”: can be used to coat parts that will not require disassembling/assembling magnets (pumping port shields, quadrupoles, drift tubes, etc)
- 10 – DCHCS technique is almost ready: need to solve the “dark area” problem and build 6.5 m cathode for MBA. Can be used to coat dipoles (MBB and MBA)

Thank you for your attention

